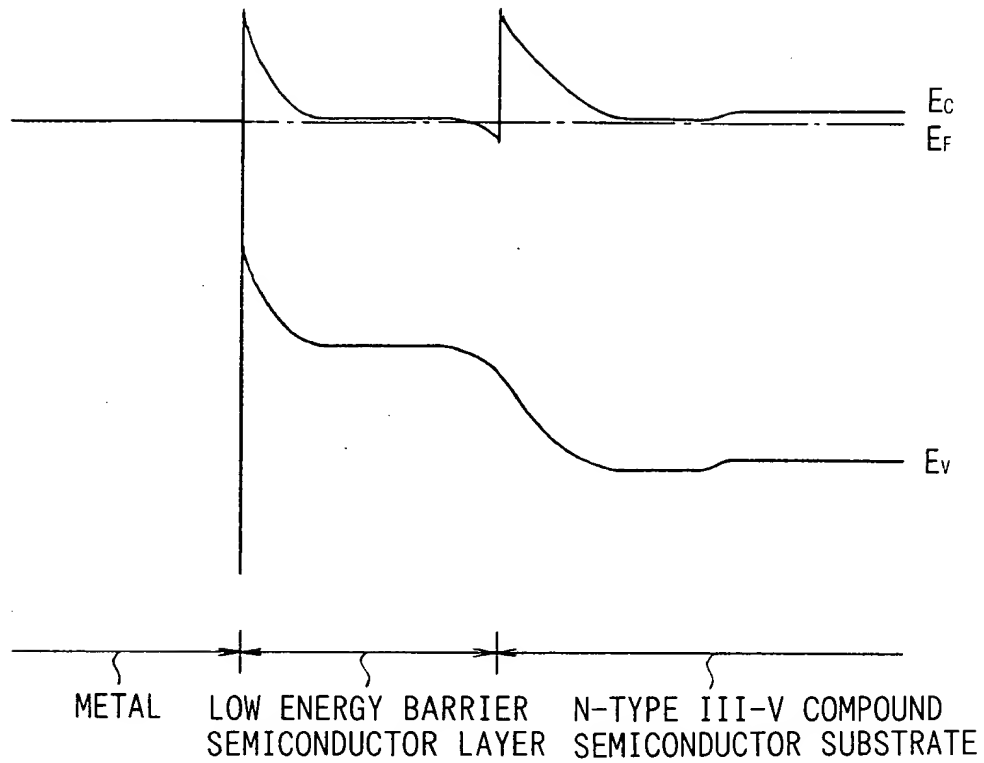
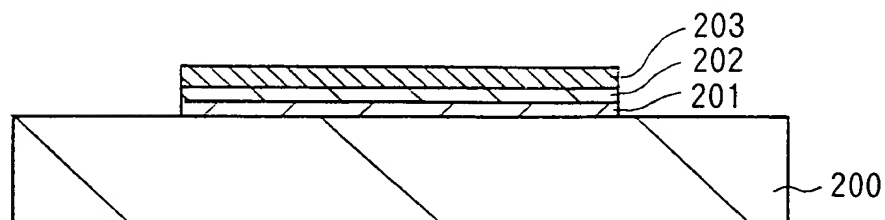


*Fig. 2**Fig. 3*

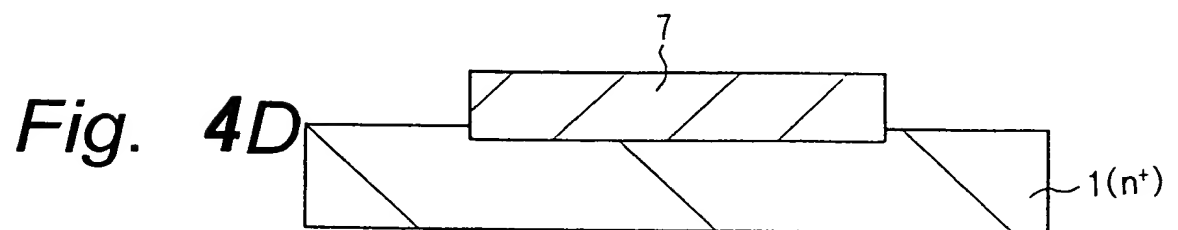
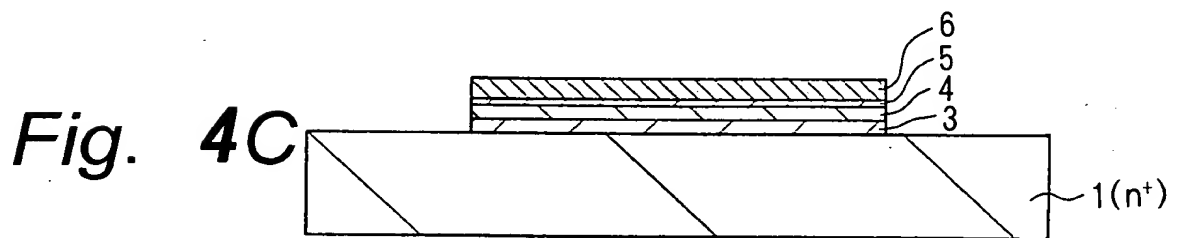
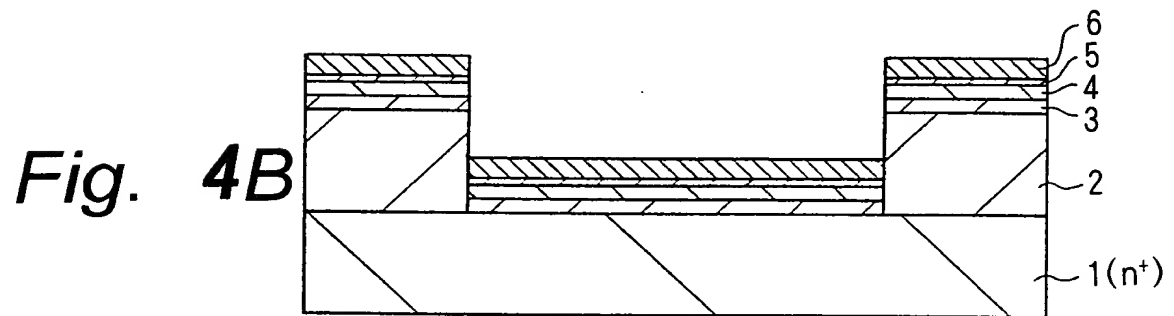
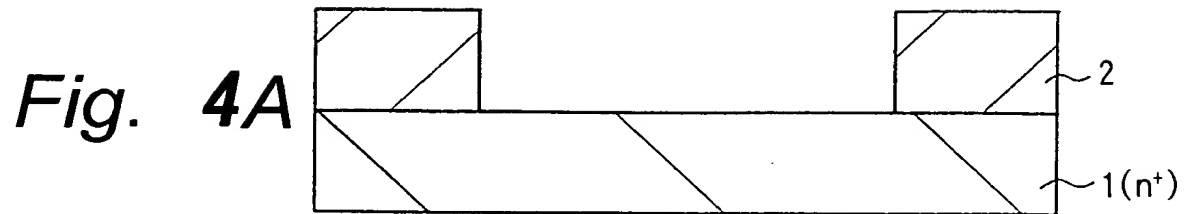


Fig. 5

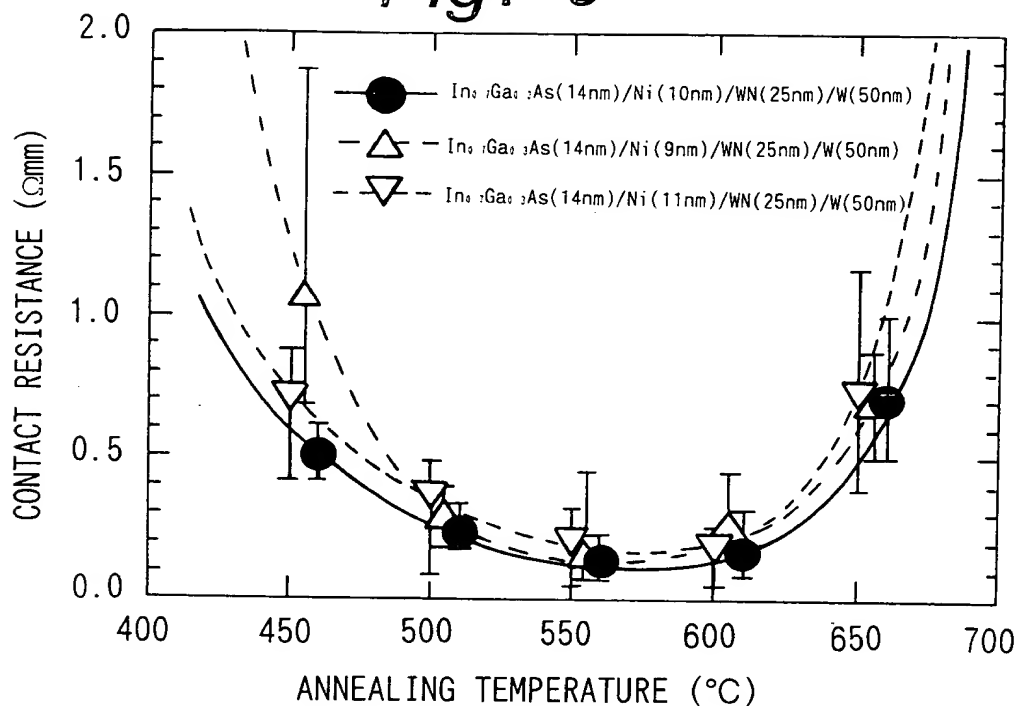


Fig. 7

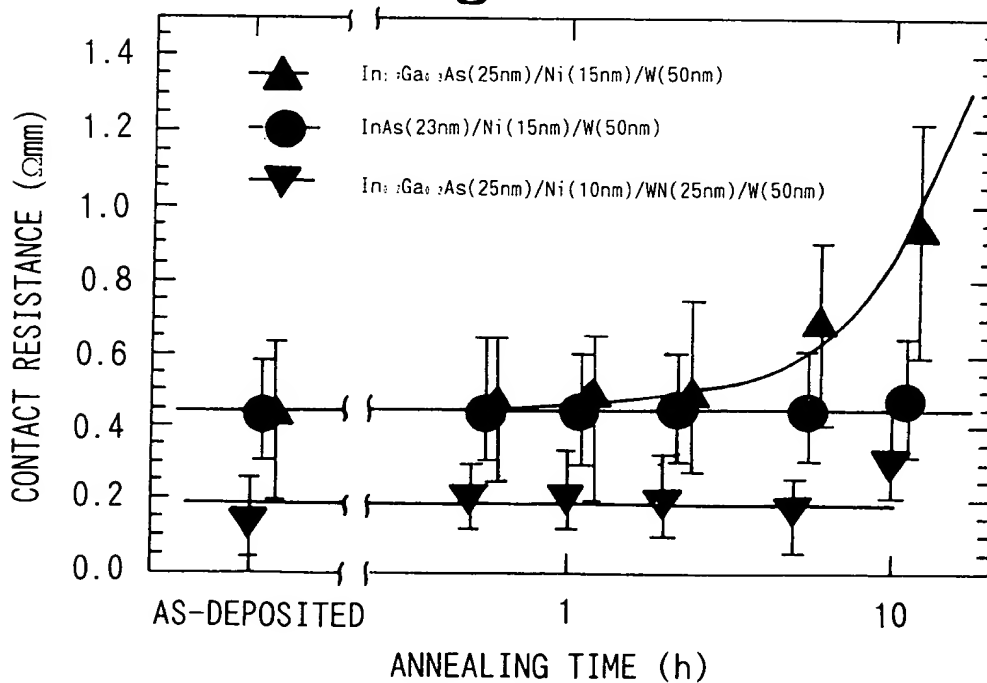
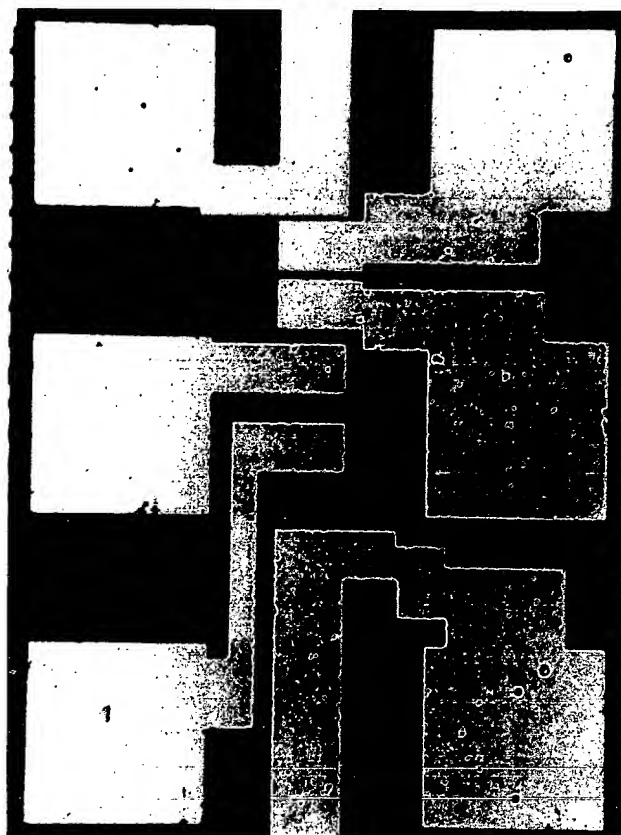
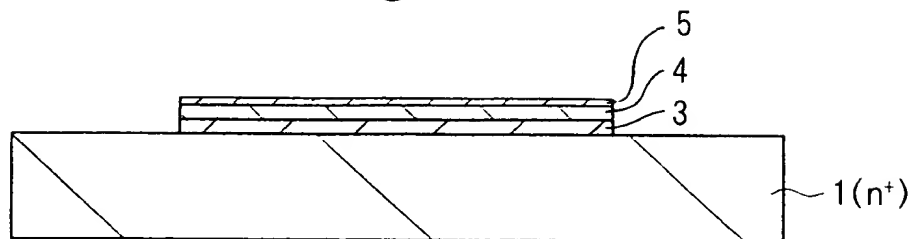
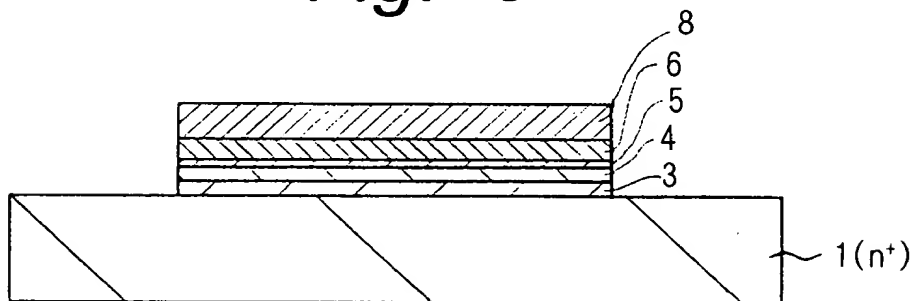


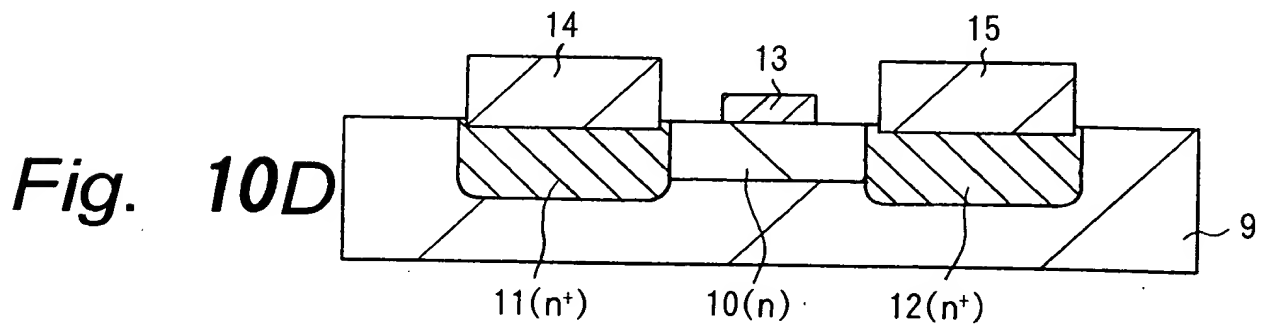
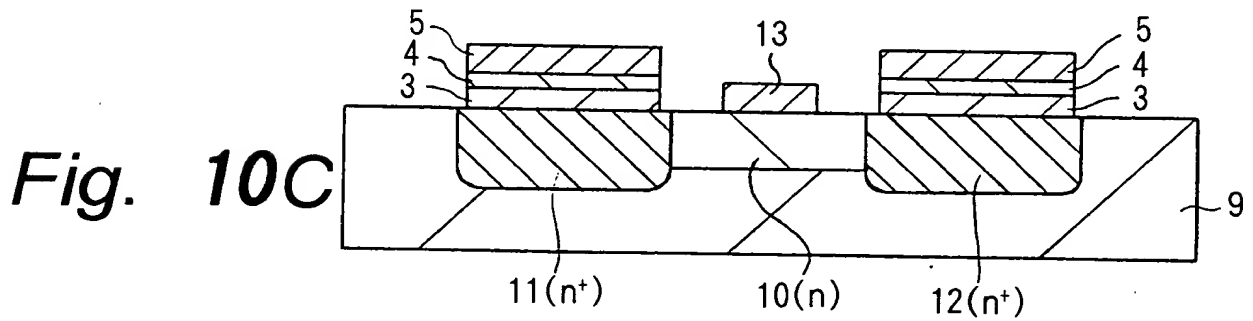
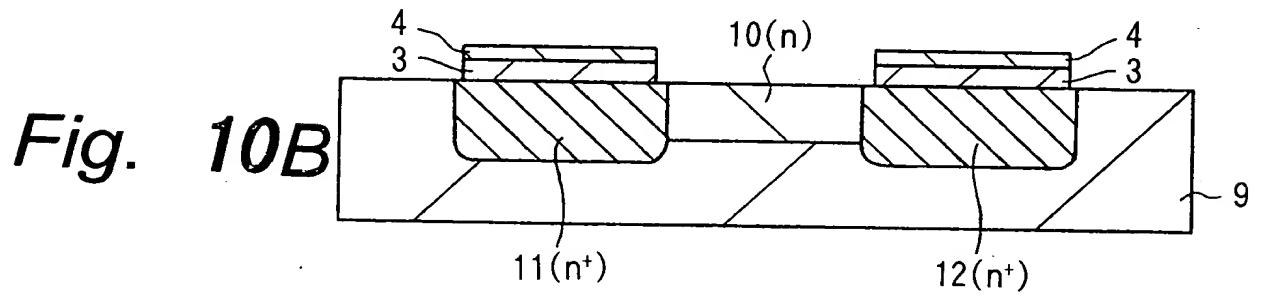
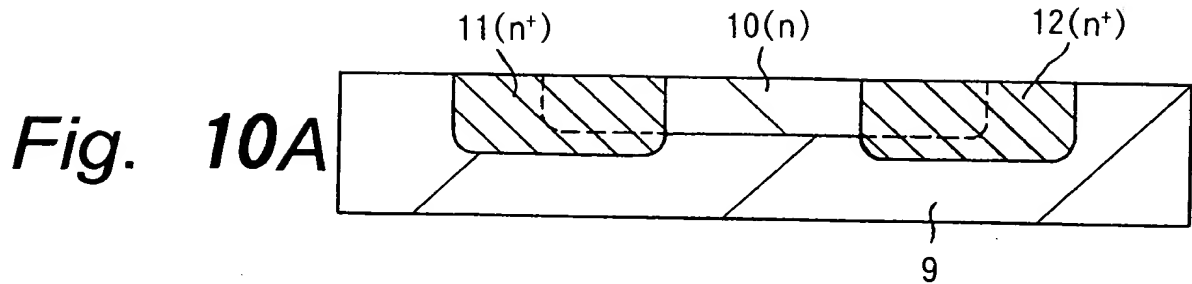
Fig. 6



50 μm

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*Fig. 8**Fig. 9*



- 1: n<sup>+</sup>-TYPE GaAs SUBSTRATE
- 3: NON-SINGLE CRYSTAL In<sub>0.7</sub>Ga<sub>0.3</sub>As LAYER
- 4: Ni FILM
- 5: WN FILM
- 6: W FILM
- 7: OHMIC ELECTRODE
- 8: Al FILM